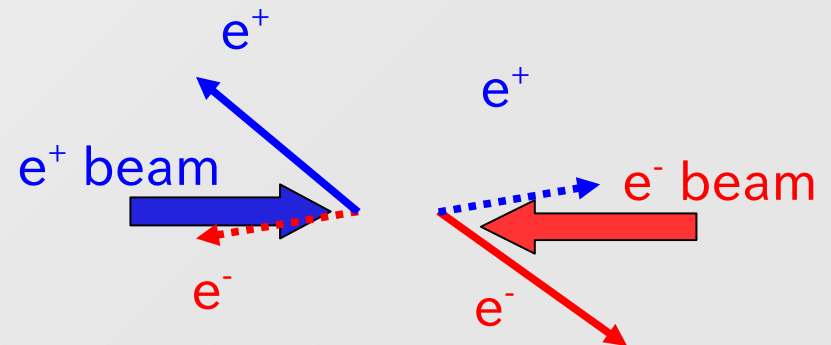
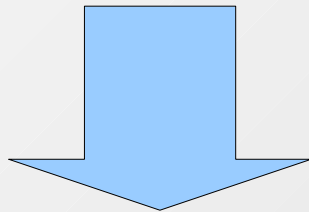


*Simulation study of
pair monitor*

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Tohoku Univ.
5 Mar 2008

Introduction

- **Pair monitor measures the beam shape at IP, using pair background.**
 - The same charges with respect to the oncoming beam are scattered with large angle.
 - The potential produced by the oncoming beam is a function of beam shape.
 - The scattered particles carry the beam information.
 - Data will be taken for each 164 bunches to get enough statistics.



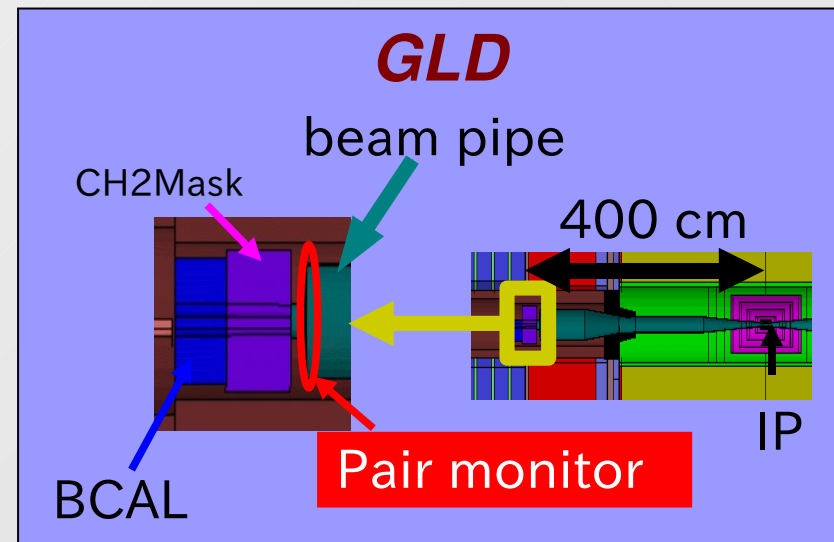
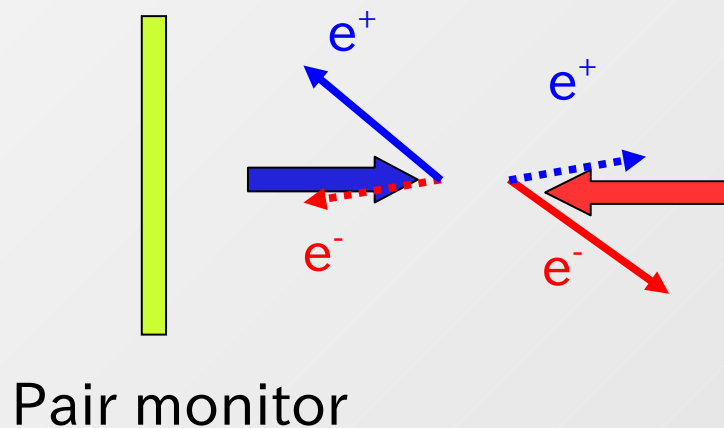
- **Activity of Tohoku group.**
 - Development of the readout ASIC.
 - Simulation study.



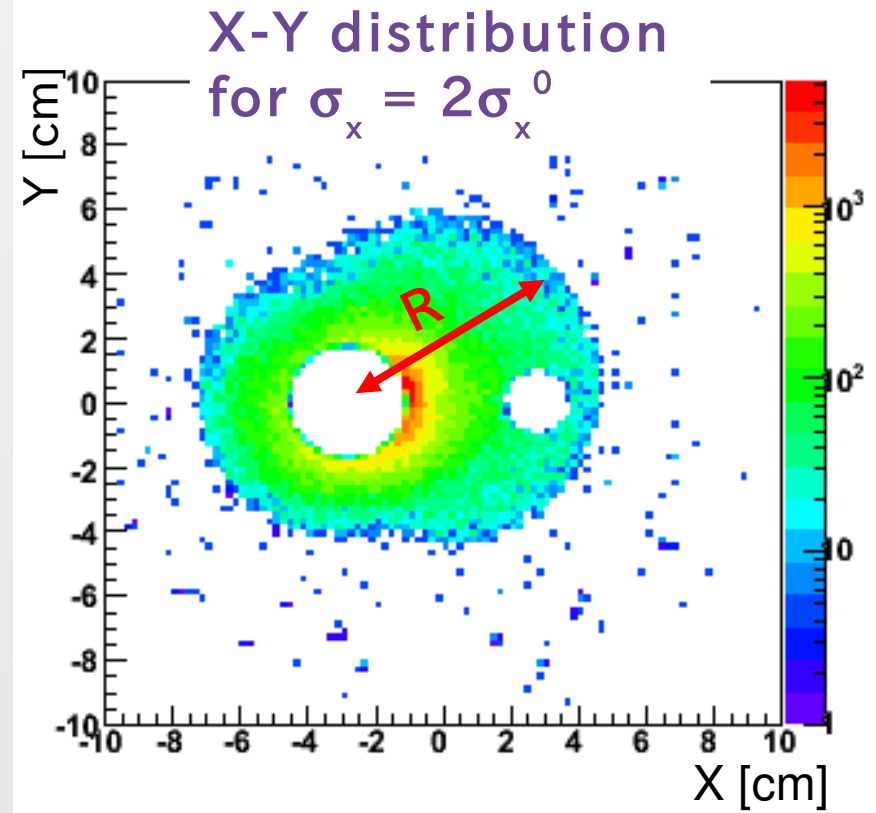
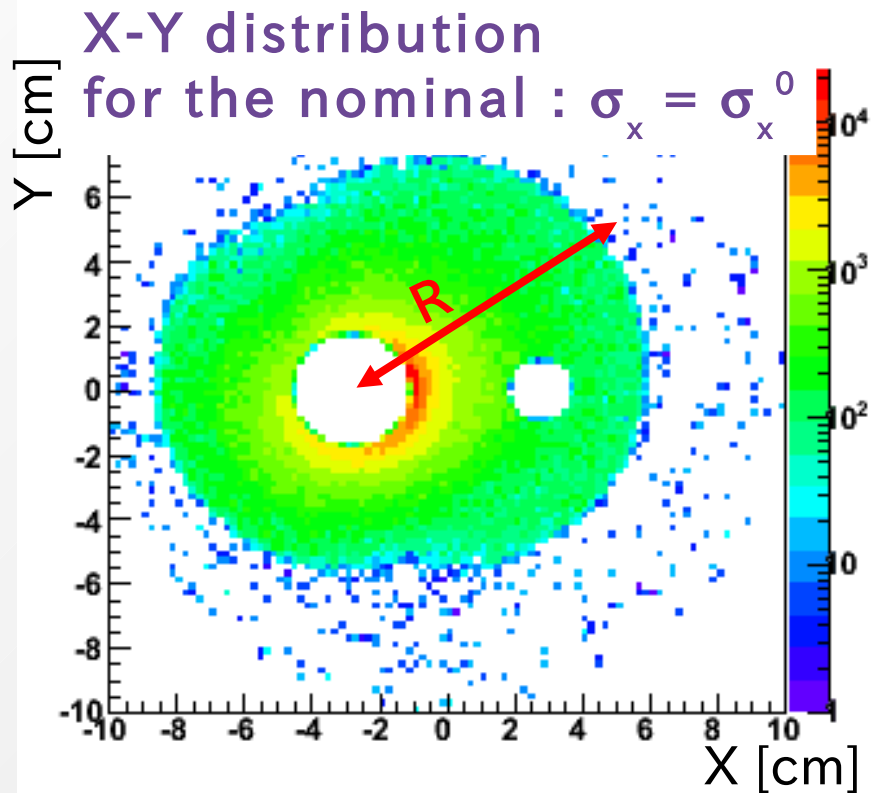
**Current status of
simulation study is shown.**

Simulation setup

- CM energy : 500 GeV
- Beam size : $(\sigma_x^0, \sigma_y^0, \sigma_z^0) = (639 \text{ nm}, 5.7 \text{ nm}, 300 \text{ mm})$
- Tools : CAIN (e^+e^- generator),
Jupiter (Tracking emulator)
 - *simulator for GLD.*
- Magnetic field : **3T with anti-DID.**
- Scattered e^+ distribution is studied.



Measurement of horizontal beam size (σ_x)

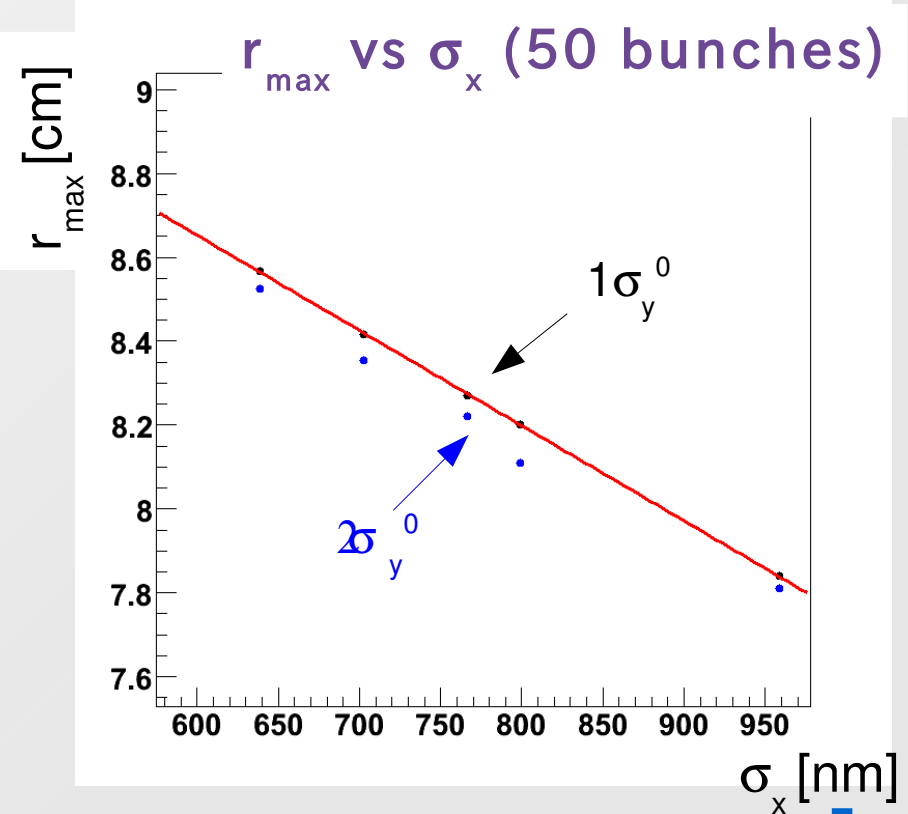
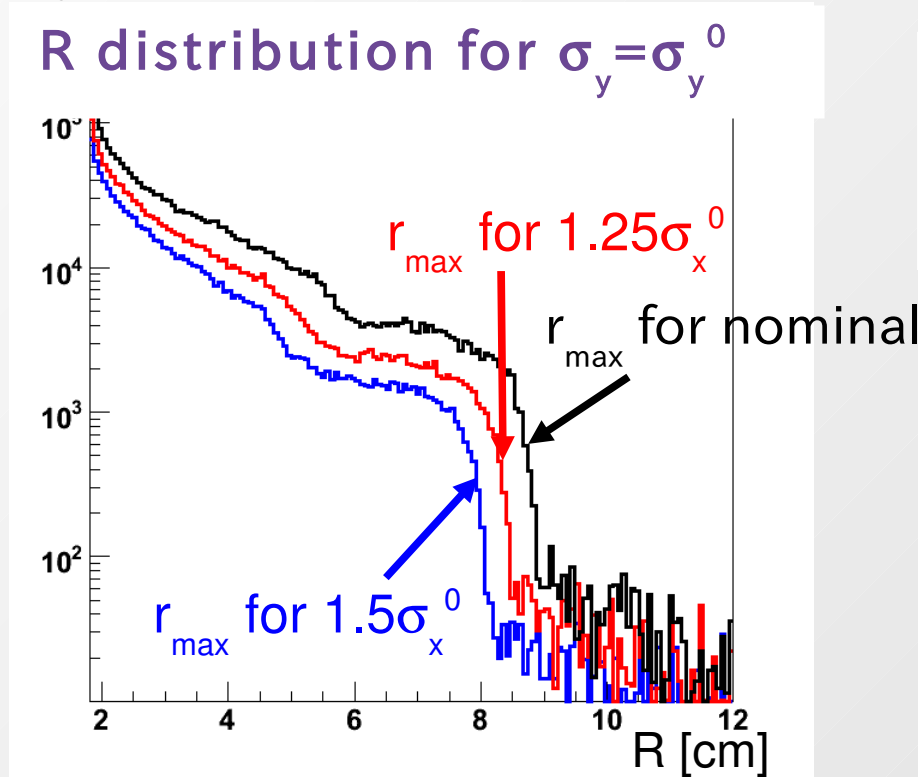


R distribution seems to depend on the horizontal beam size (σ_x).

The maximum R was studied.

Radial distribution and r_{max}

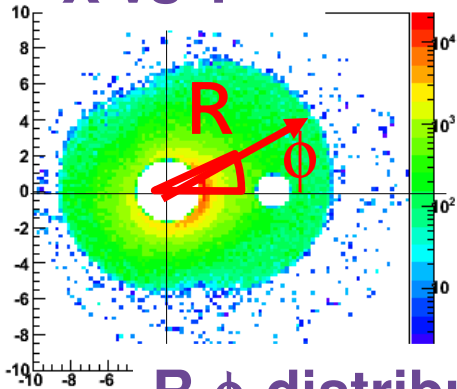
- r_{max} – radius to contain 99.8% of the all hits.



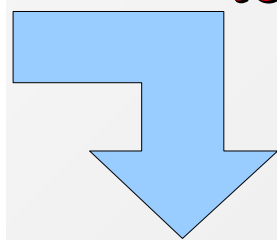
The statistical error is scaled to that of 164 bunches.
Horizontal beam size (σ_x) can be measured by
resolution of 0.75 nm for the nominal beam size.

Measurement of vertical beam size (σ_y)

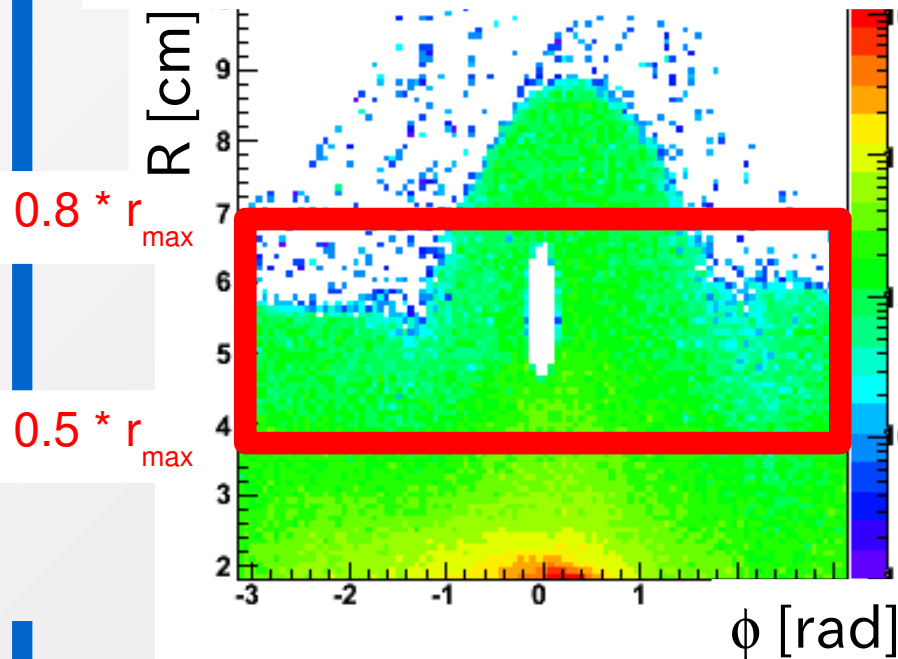
X vs Y



- To derive the beam information, projection to ϕ -axis is checked.

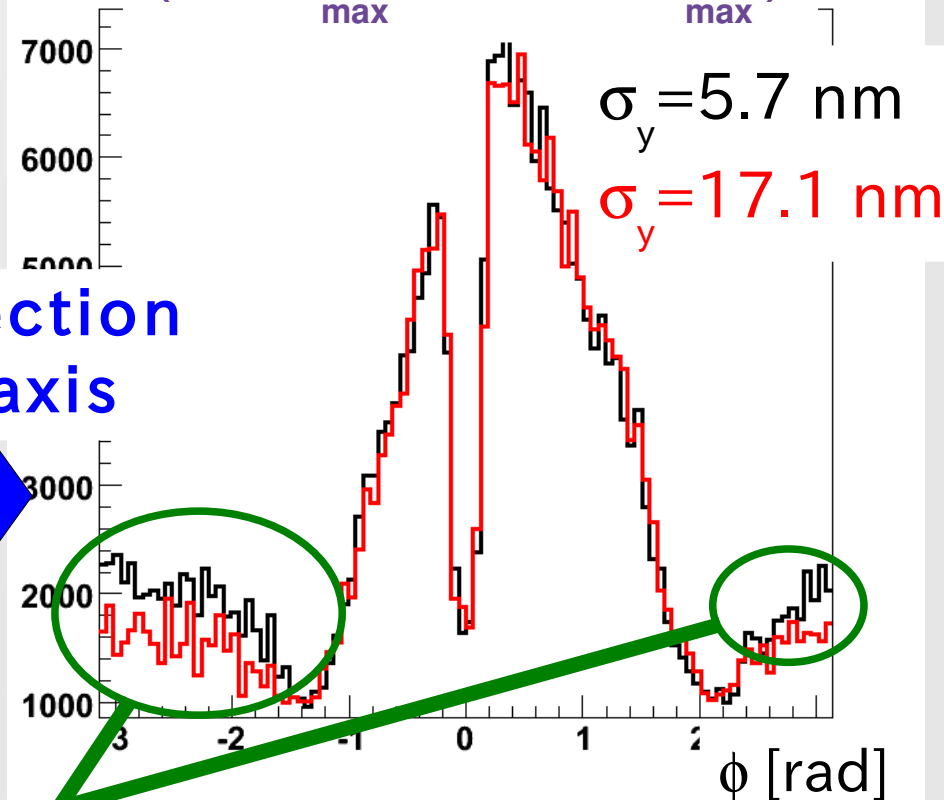


R- ϕ distribution for the nominal



ϕ distribution

($0.5 * r_{max} < R < 0.8 * r_{max}$)



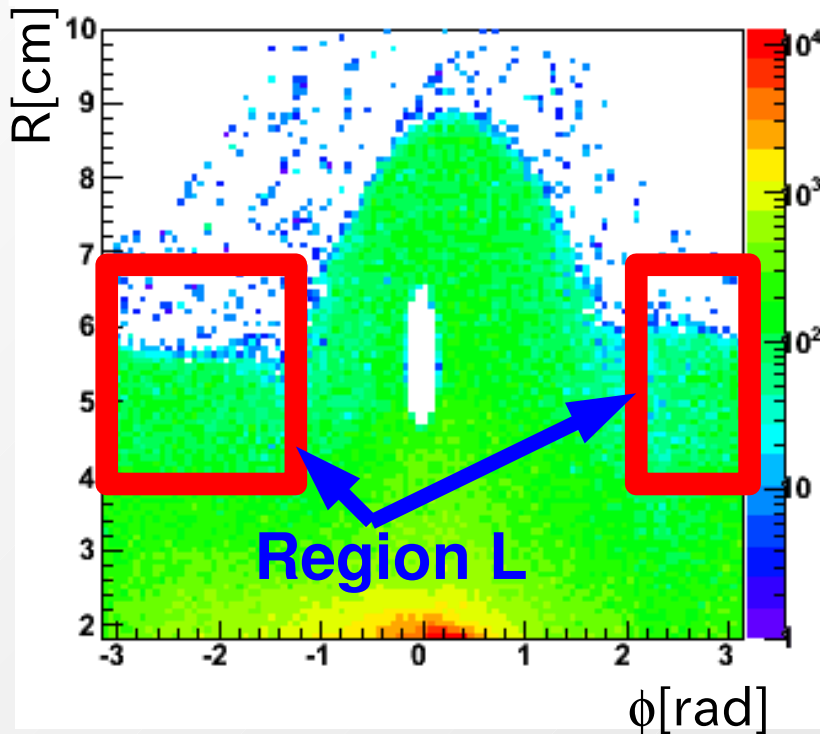
Projection to ϕ -axis



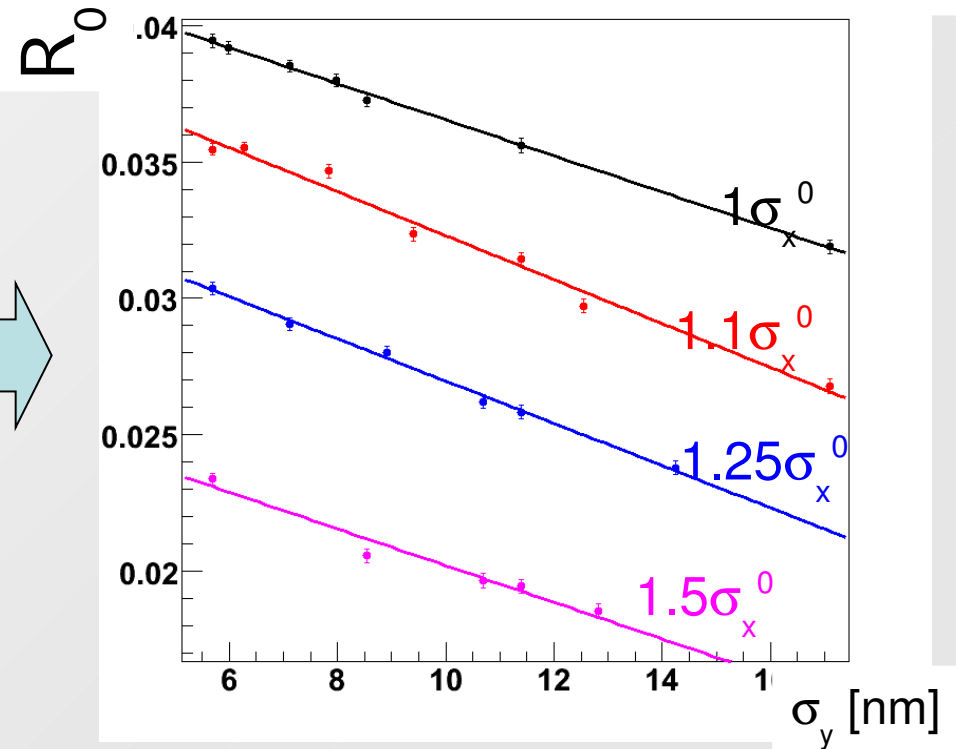
There is the information of σ_y in this region.

Resolution of vertical beam size (σ_y)

R- ϕ distribution for the nominal



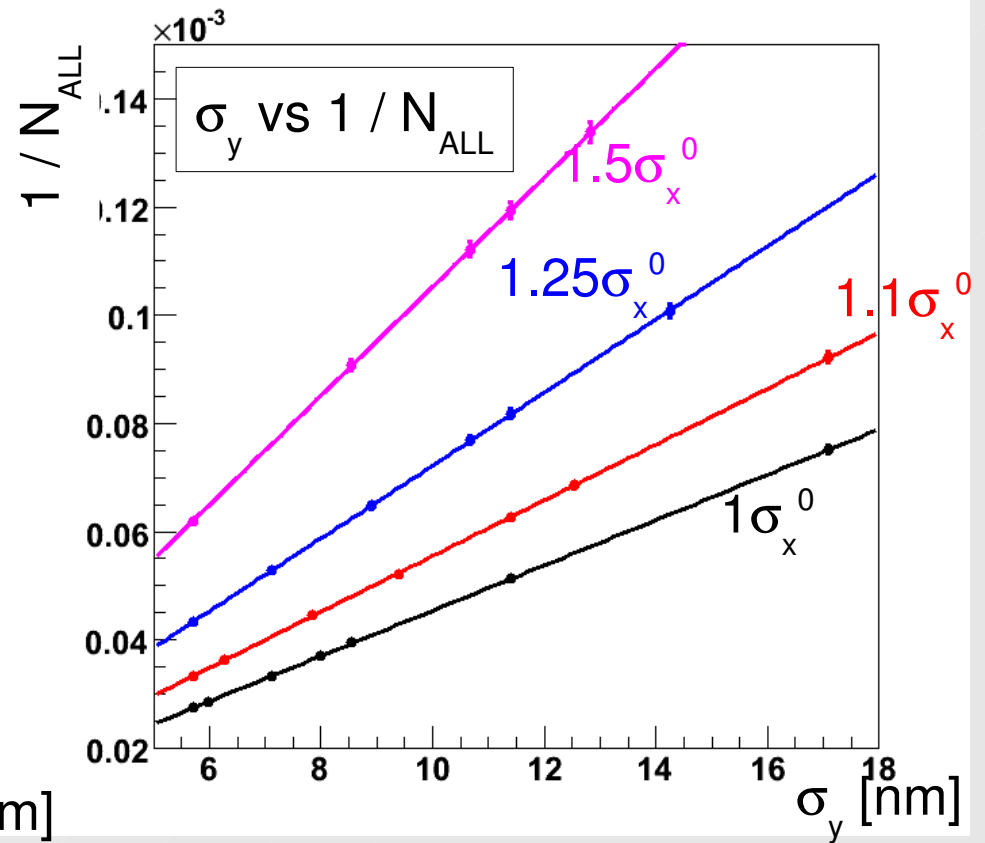
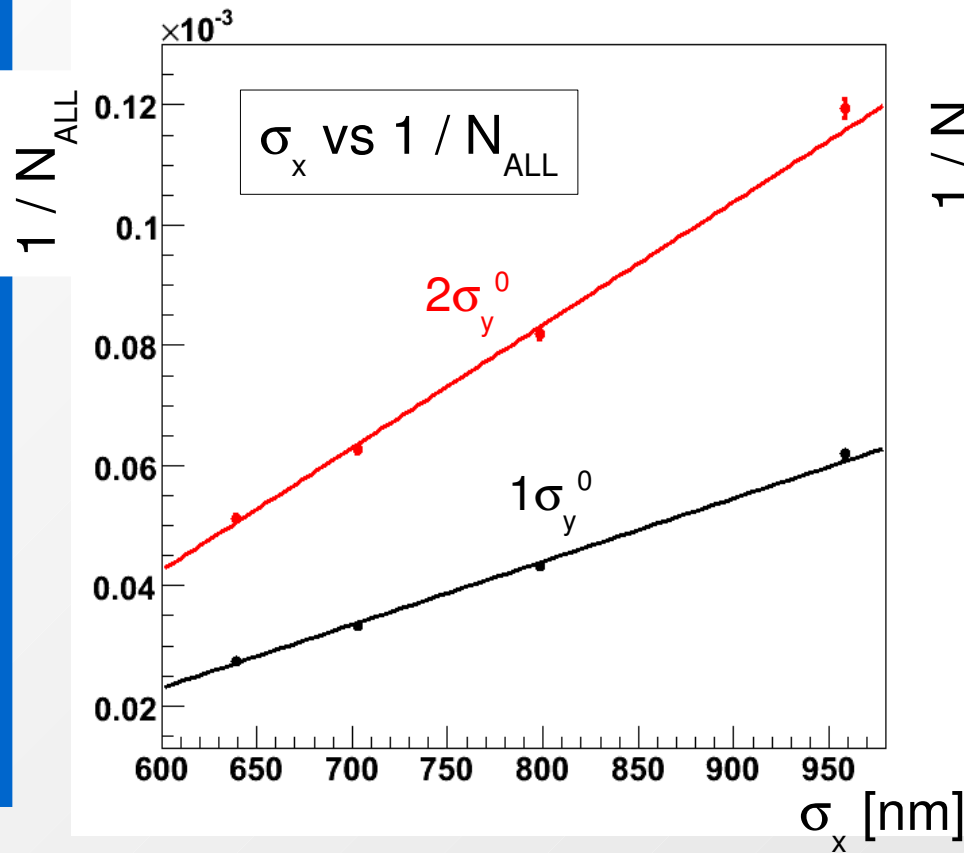
$R_0 = N_L / N_{ALL}$ (50 bunches)



The statistical error is scaled to that of 164 bunches. Vertical beam size (σ_y) can be measured by resolution of 0.20 nm (3.5%) for the nominal beam size.

The number of all hits per bunch (N_{ALL})

- The number of hits also have information of beam shape.



$1/N_{ALL}$ has linear dependence on beam size (σ_x, σ_y).

Is it possible to measure σ_x and σ_y with r_{max} , R_0 and $1/N_{ALL}$?

Measurement of vertical and horizontal beam size (σ_x, σ_y)

$$\left\{ \begin{aligned} r_{max}(\sigma_x, \sigma_y) &= r_{max}(\sigma_x^0, \sigma_y^0) + \frac{\partial r_{max}}{\partial \sigma_x}(\sigma_x - \sigma_x^0) + \frac{\partial r_{max}}{\partial \sigma_y}(\sigma_y - \sigma_y^0) + \dots \\ R_0(\sigma_x, \sigma_y) &= R_0(\sigma_x^0, \sigma_y^0) + \frac{\partial R_0}{\partial \sigma_x}(\sigma_x - \sigma_x^0) + \frac{\partial R_0}{\partial \sigma_y}(\sigma_y - \sigma_y^0) + \dots \\ \frac{1}{N_{ALL}}(\sigma_x, \sigma_y) &= \frac{1}{N_{ALL}}(\sigma_x^0, \sigma_y^0) + \frac{\partial}{\partial \sigma_x} \left(\frac{1}{N_{ALL}} \right) (\sigma_x - \sigma_x^0) + \frac{\partial}{\partial \sigma_y} \left(\frac{1}{N_{ALL}} \right) (\sigma_y - \sigma_y^0) + \dots \end{aligned} \right.$$

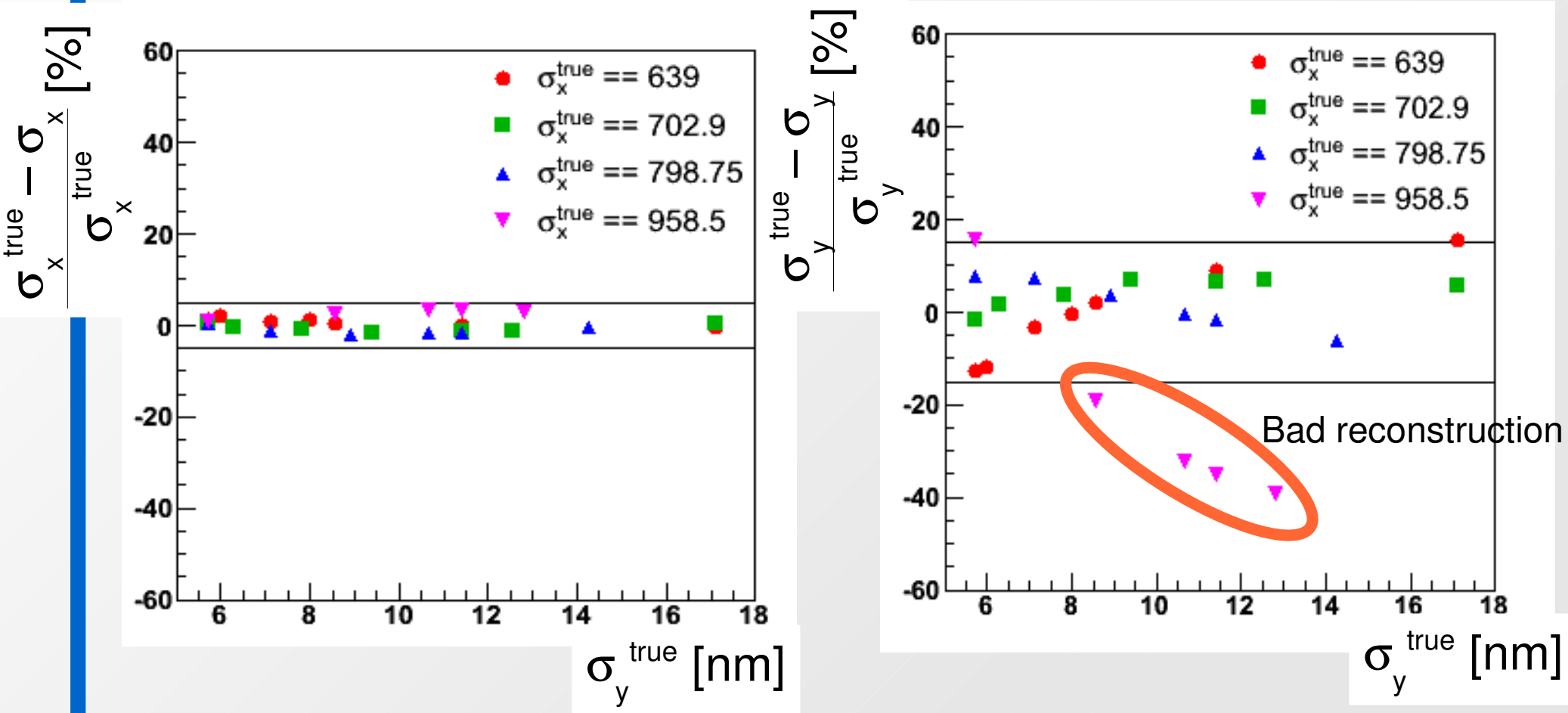
$$\begin{pmatrix} \alpha \times (r_{max} - r_{max}^0) \\ \beta \times (R_0 - R_0^0) \\ \chi \times \left(\frac{1}{N_{ALL}} - \frac{1}{N_{ALL}^0} \right) \end{pmatrix} = \begin{pmatrix} \alpha \times \frac{\partial r_{max}}{\partial \sigma_x} & \alpha \times \frac{\partial r_{max}}{\partial \sigma_y} \\ \beta \times \frac{\partial R_0}{\partial \sigma_x} & \beta \times \frac{\partial R_0}{\partial \sigma_y} \\ \chi \times \frac{\partial}{\partial \sigma_x} \left(\frac{1}{N_{ALL}} \right) & \chi \times \frac{\partial}{\partial \sigma_y} \left(\frac{1}{N_{ALL}} \right) \end{pmatrix} \begin{pmatrix} \sigma_x - \sigma_x^0 \\ \sigma_y - \sigma_y^0 \end{pmatrix}$$

α, β, χ are weights.

$$m = Ax$$

$$(A^T A)^{-1} A^T m = x = \begin{pmatrix} \sigma_x - \sigma_x^0 \\ \sigma_y - \sigma_y^0 \end{pmatrix}$$

Results

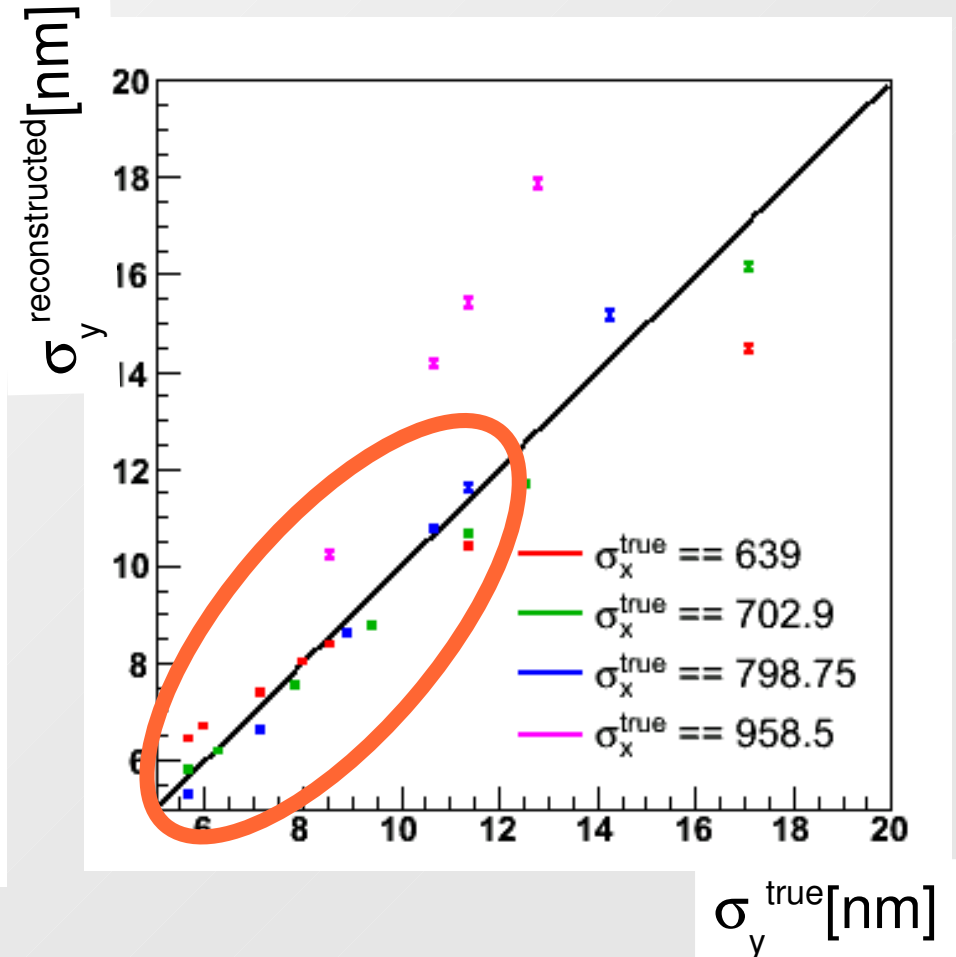
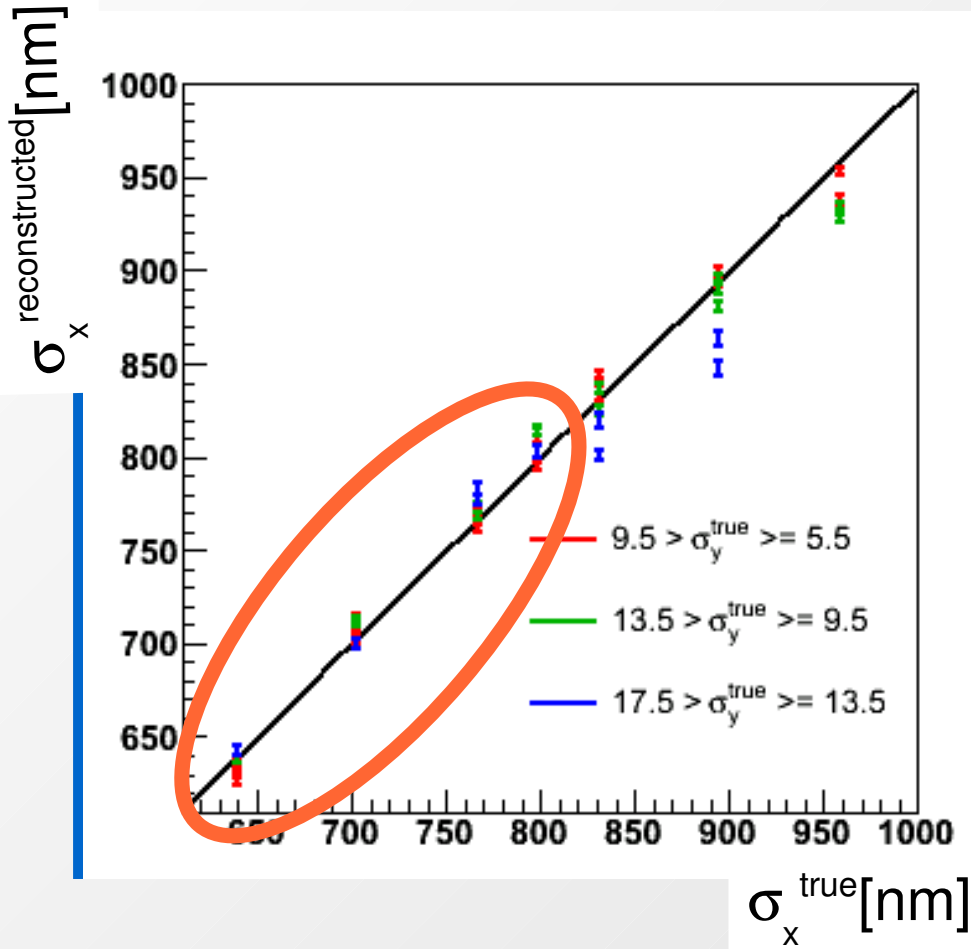


σ_x can be measured with 5%.

σ_y can be measured with 15%.

Measurement of σ_y should be improved to 10% accuracy.

True value vs reconstructed value



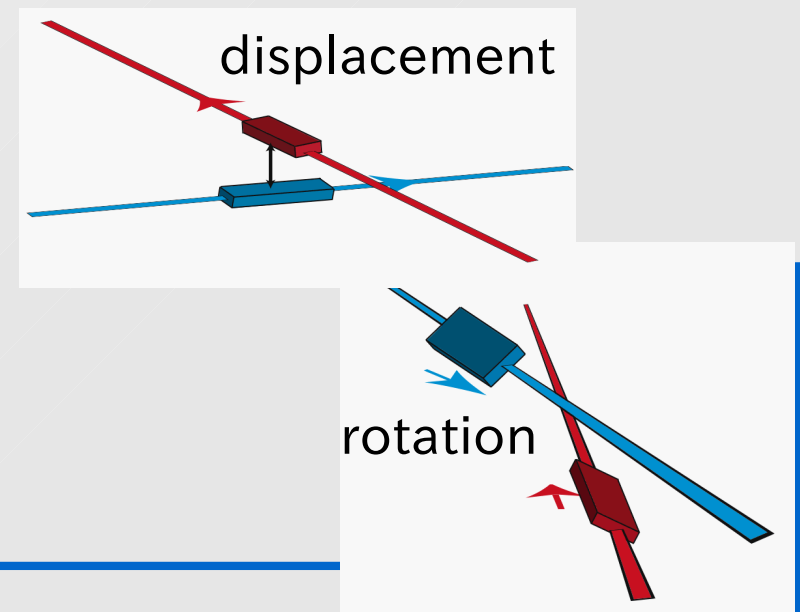
The matrix method works for around the nominal beam size.

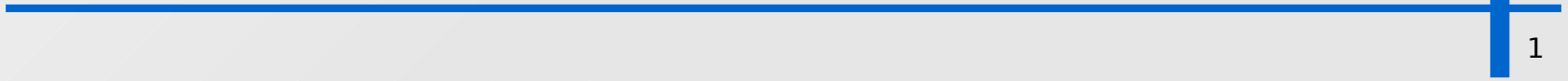
Conclusions

- Pair monitor measures the beam shape at IP.
- Single measurement
 - Vertical beam size (σ_y) can be measured by 0.20 nm for the standard beam.
 - Horizontal beam size (σ_x) can be measured by 0.75 nm for the standard beam.
- Double measurement(σ_x and σ_y) is started with matrix.

Plans

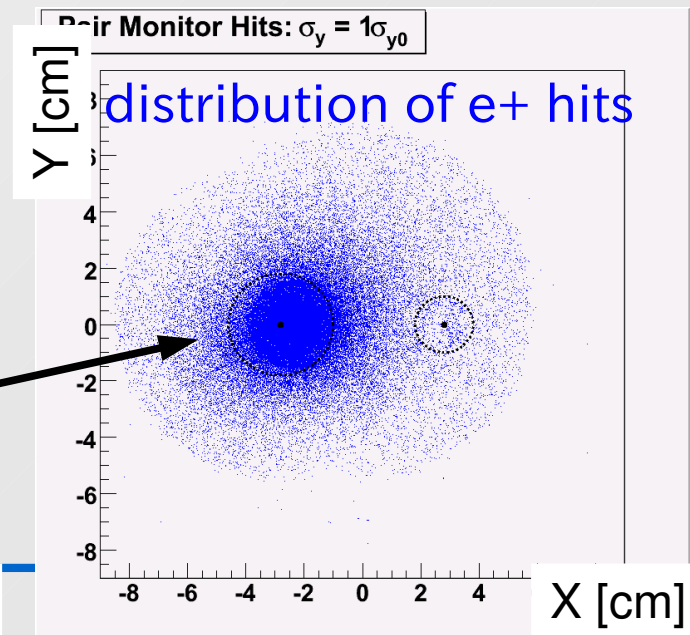
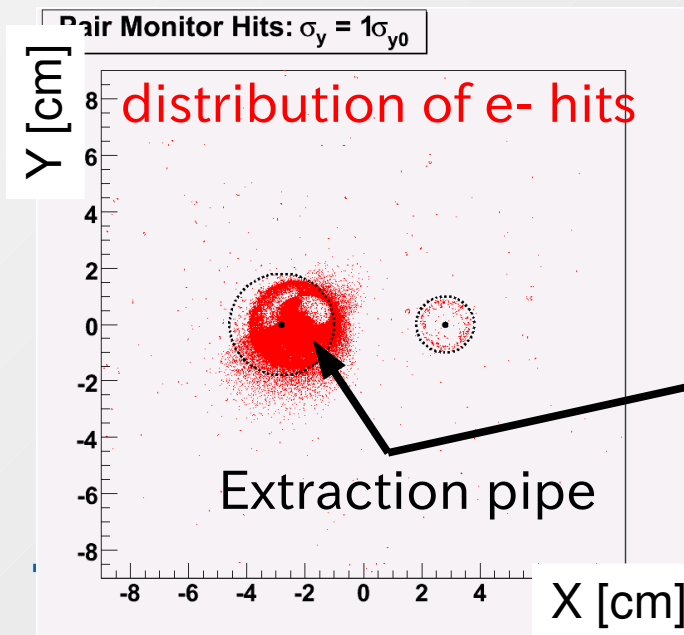
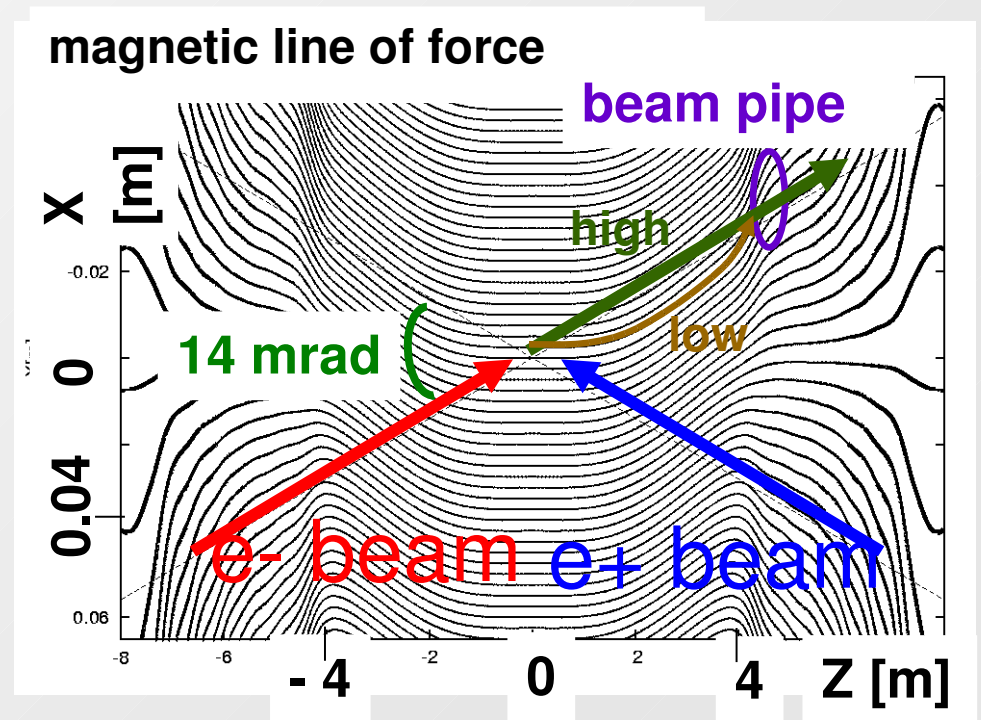
- Measurement of more beam information.
 - displacement, rotation, ...
- Simulation study with more accurate magnetic field.
 - 3-D magnetic field map of GLD will be prepared.





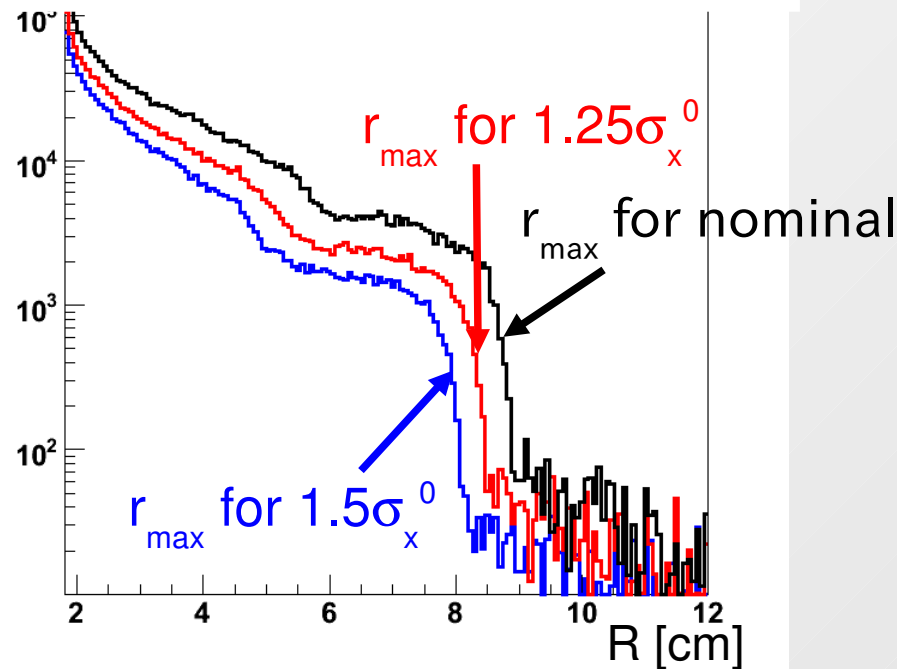
anti-DID field

- anti-DID is the magnetic field to lead the pair backgrounds to the beam pipe.
- anti-DID field of the first order of approximation was used.

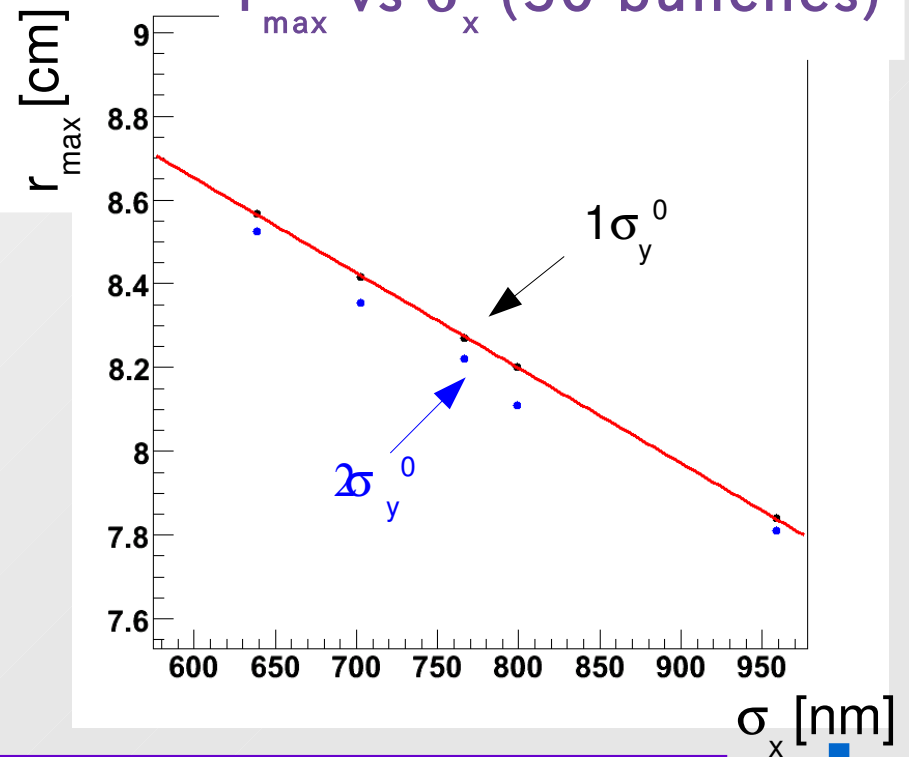


Radial distribution

R distribution for $\sigma_y = \sigma_y^0$



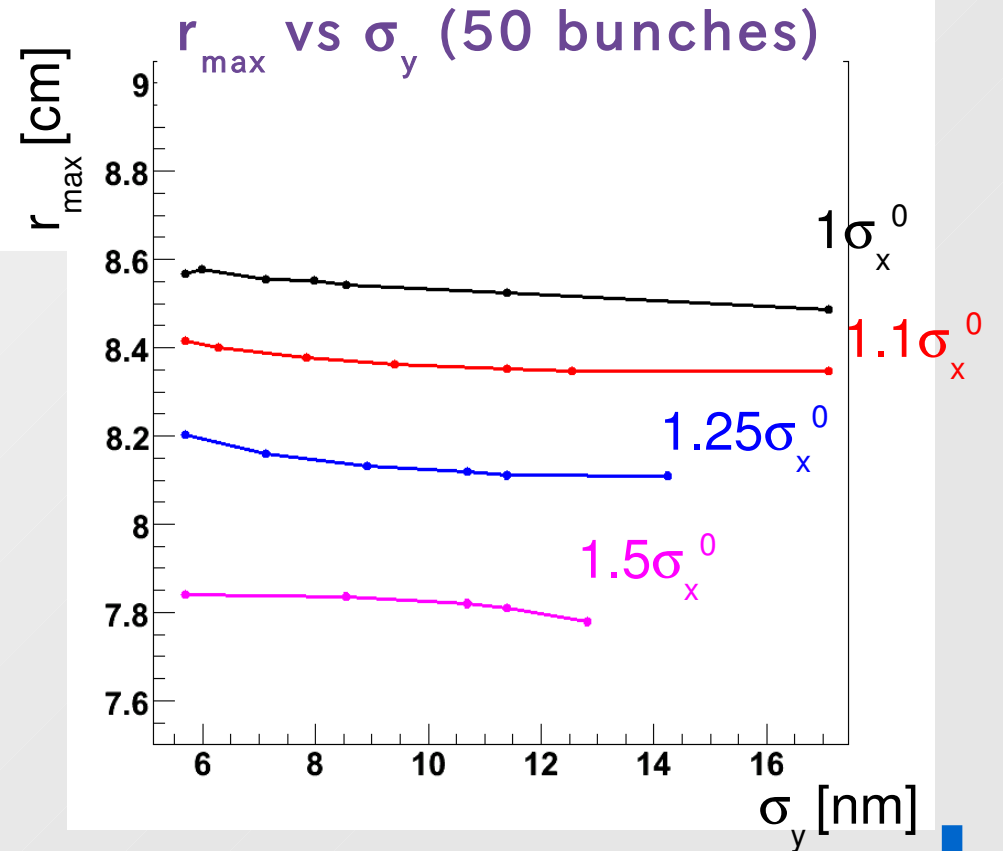
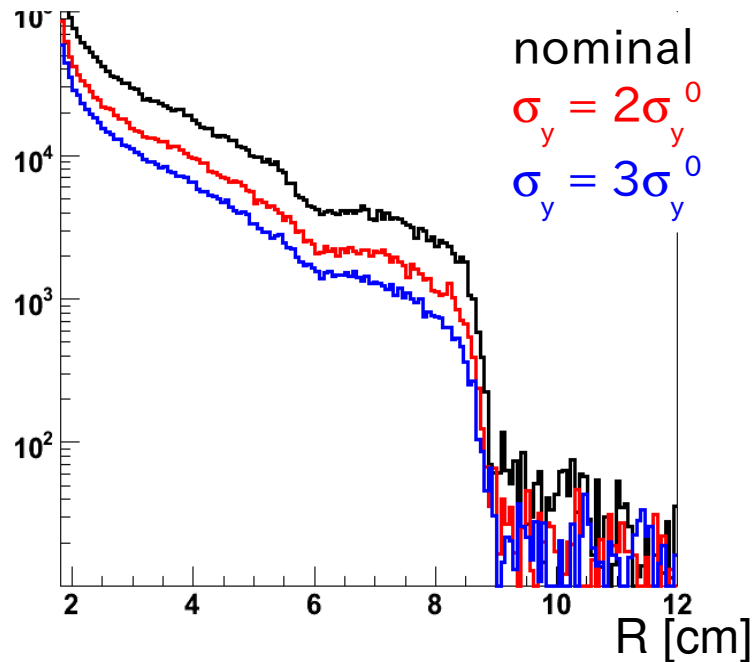
r_{\max} vs σ_x (50 bunches)



r_{\max} depend on horizontal beam size (σ_x).

Radial distribution

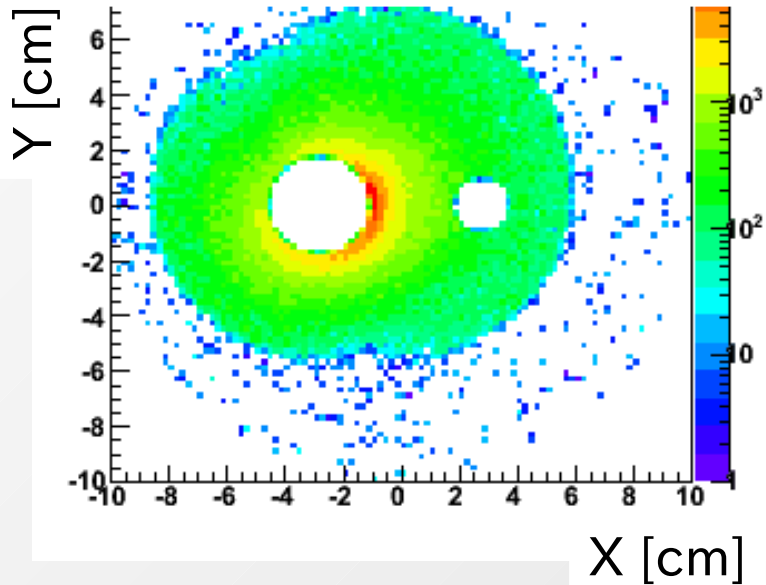
R distribution for $\sigma_x = \sigma_x^0$



r_{\max} does not depend on vertical beam size (σ_y).

The Hit distribution changes with σ_y

X-Y distribution
for the nominal : $\sigma_y = \sigma_y^0$



X-Y distribution
for $\sigma_y = 3\sigma_y^0$

